\$1286.00

T 202.293.7060 F 202.293.7860

www.sughrue.com



March 25, 2004

3

MAIL STOP PATENT APPLICATION

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Re:

Application of Ryu OHTAGURO and Koichi HASHIGUCHI

SUBSTRATE FOR PHOTOMASK, PHOTOMASK BLANK AND PHOTOMASK

Assignee: HOYA CORPORATION

Our Ref. Q80708

Dear Sir:

Attached hereto is the application identified above comprising thirty-one (31) sheets of the specification, including the claims and abstract, and three (3) sheets of drawings. The requisite U.S. Government Filing Fee, copies of the executed Declaration and Power of Attorney and Assignment will be submitted at a later date. Also enclosed is an Information Disclosure Statement and PTO/SB/08 A & B (modified).

The Government filing fee is calculated as follows:

Total claims	14	-	20	=	>	ĸ	\$18.00	=	\$.00
Independent claims	9	-	3	=	6 >	ĸ	\$86.00	=	\$516.00
Base Fee									\$770.00

TOTAL FEE

Priority is claimed from:

Country Application No Filing Date

Japan 2003-84992 March 26, 2003

Japan 2004-73763 March 16, 2004

The priority documents will be filed at a later date.

Respectfully submitted, SUGHRUE MION, PLLC

Attorneys for Applicant

SUGHRUE MION, PLLC Telephone: (202) 293-7060

Facsimile: (202) 293-7860

WASHINGTON OFFICE

23373

CUSTOMER NUMBER

Darryl Mexic

Registration No. 23,063